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Potential Improvement in Fill Factor of Lead-Halide Perovskite Solar Cells

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Abstract

In this study, the origin of fill factor (FF) in lead-halide perovskite solar cells is discussed based on different thickness of 2,2',7,7'-tetrakis(*N*,*N*-di-*p*-methoxyphenylamine)-9,9-spirobifluorene (spiro-OMeTAD) as a hole-transporting layer (HTL). As the thickness of HTL is decreased, the FF increases and hence the photovoltaic performance is also improved. This is mainly ascribed to the reduced series resistance with decreasing HTL thickness. Such improvement in FF is examined on the basis of an empirical equation for FF with the diode and photovoltaic parameters. As a result, the thickness-dependent FF can be well explained by this equation. The potential improvements in FF and PCE are further discussed on the basis of the empirical equation.

1. Introduction

Organic–inorganic perovskites based on lead halides have attracted a great deal of interest as one of the most promising materials for next-generation photovoltaic devices because they exhibit excellent optoelectronic properties, such as direct bandgap with high absorption coefficient, high charge carrier mobility, low exciton binding energy, and long diffusion length and lifetime of charge carriers despite being processed through solution processes at room temperature.^[1–5] Thus, intensive research efforts have been devoted not only to optimizing the device architecture but also to preparing high-quality perovskite layers with superior reproducibility to improve the power conversion efficiency (PCE) of perovskite solar cells.^[3,4,6–9] As a result, the perovskite solar cells have shown remarkable improvements in the PCE from 3.8% in 2009^[10] to more than 22% in 2016.^[6,11] Further improvements are still anticipated from the academic and commercial points of view. As such, it is of vital importance to discuss marginal efficiency of perovskite solar cells.

Highly efficient photovoltaic parameters have been reported for lead-halide perovskite solar cells in the last few years. The short-circuit current density (J_{SC}) has been improved up to $\approx 24 \text{ mA cm}^{-2}$ for the device with a thick active layer ($\approx 500 \text{ nm}$),^[7–9,12] which is almost comparable to the maximum photocurrent taking into account the reflection loss of incoming light.^[13] The open-circuit voltage (V_{OC}) has been reported to be typically in the range of 0.90– 1.24 V at room temperature, ^[14–17] which are lower by about 0.4–0.7 eV than their bandgap (E_g) of $\approx 1.6 \text{ eV}.^{[4,17,18]}$ As reported previously,^[8,19–21] this voltage loss is ascribed to direct recombination and trap-assisted Shockley–Read–Hall (SRH) recombination, the latter of which is dependent upon the trap density N_t in perovskite active layers. We have shown that V_{OC} could be improved up ≈ 1.3 V if trap density were reduced to $N_t < 10^{13} \text{ cm}^{-3}.^{[7]}$ The fill factor (FF) has been reported to be in the range of 0.70–0.85 for efficient perovskite solar cells.^[14–17,22–24] However, most of them are still dependent on the voltage sweep direction because of J-Vhysteresis. Consequently, it has been difficult to discuss the FF of perovskite solar cells

quantitatively. In other words, quantitative analyses of the FF are highly required to discuss the marginal efficiency of perovskite solar cells.

In this study, we discuss the limiting factors in FF of lead-halide perovskite solar cells with different thicknesses of 2,2',7,7'-tetrakis(N,N-di-p-methoxyphenylamine)-9,9-spirobifluorene (spiro-OMeTAD) employed as a hole-transporting layer (HTL). With decreasing HTL thickness, FF increased and hence the photovoltaic performance was also improved. This is ascribed mainly to the smaller series resistance with decreasing HTL thickness. We examined this improvement in FF on the basis of an empirical equation for FF with the diode and photovoltaic parameters. As a result, we found that the thickness dependence of FF can be well explained by this equation. Thus, we further discuss the potential improvement in FF and PCE on the basis of the empirical equation.

2. Results and Discussion

Figure 1a shows the *J*–*V* characteristics of perovskite solar cells based on dense TiO₂ with different HTL thickness, which were measured from 1.1 to -0.10 V (reverse scan) with a delay time of 1 s under AM 1.5G simulated solar illumination with 100 mW cm⁻². All the devices exhibited highly reproducible photovoltaic performance. As summarized in **Table 1**, the *J*_{SC} and *V*_{OC} were almost independent of the HTL thickness. On the other hand, the FF increased with decreasing HTL thickness. As shown in Figure 1b, the external quantum efficiency (EQE) was as high as more than 90% over the broad wavelength from 400 to 750 nm, which is consistent with the *J*_{SC} observed (≈24 mA cm⁻²). As shown in Figure S1 (see the Supporting Information), the *J*_{SC} and *V*_{OC} were almost independent of the scan directions while the FF observed for the forward scan (-0.1 to 1.1 V) was smaller by about 7% than those for the reverse scan (1.1 to -0.10 V). Therefore, we should consider the hysteresis effect to discuss the FF quantitatively as described later.

First, we analyzed the J-V characteristics in the dark on the basis of the equivalent circuit model to evaluate the series resistance R_s and the parallel resistance R_p . In this model, the current density J is given by^[25,26]

$$J = J_0 \left\{ \exp\left[\frac{q(V - JR_s)}{n_{id}k_BT}\right] - 1 \right\} + \frac{V - JR_s}{R_p} - J_{ph}$$
(1)

where J_0 is the saturation current density at reverse bias, q is the elementary charge, n_{id} is the ideality factor, k_B is the Boltzmann constant, T is the absolute temperature, and J_{ph} is the photocurrent density. Here, as shown in **Figure 2**a and Figure S2, the ideality factor n_{id} was separately evaluated from a slope in V_{OC} plotted against the logarithm of J_{SC} based on Equation (2) rather than from the J-V characteristics in the dark because the J-V characteristics in the dark because the J-V characteristics in the dark are strongly affected by both the R_s and R_p resistances.^[25,26]

$$V_{\rm OC} = \frac{n_{\rm id} k_{\rm B} T}{q} \ln \left(\frac{J_{\rm SC}}{J_0} \right) \tag{2}$$

As summarized in Table 2, the n_{id} was evaluated to be 1.6 for the forward scan and 1.3 for reverse scan, which were independent of the HTL thickness. By using the n_{id} obtained, both R_s and R_p resistances were evaluated from the J–V characteristics in the dark with Equation (1) as shown in Figure S3. As summarized in Table 2, the R_p resistance was more than $10^5 \Omega$ cm² for all the HTL thicknesses. This is probably because the perovskite films prepared are dense and pin-hole free enough to suppress the leakage current. On the other hand, as shown in Figure 2b, the R_s resistance monotonically decreases with decreasing HTL thickness from 310 to 170 nm and reaches 3.4 Ω cm² at an HTL thickness of 0 nm. From the slope of the thicknessdependent R_s component, the conductivity is evaluated to be 5.6 × 10⁻⁶ S cm⁻¹, which is in good agreement with that evaluated for spiro-OMeTAD films as shown in Figure S4. These values are also comparable to the conductivity reported for spiro-OMeTAD films exposed in air for 20 min.^[27] We therefore ascribe the thickness-dependent R_s component to the film resistance of the HTL material. The remaining constant component (3.4 Ω cm²) is probably due to the film resistance of d-TiO₂ layer and the contact resistances at the interfaces. The resistance of d-TiO₂ layer has been reported to be $\approx 0.4 \Omega$ cm² for a thickness of 40 nm, which is much smaller than the constant component observed.^[28] This suggests that the constant fraction is mainly due to the contact resistances rather than the film resistance of d-TiO₂ layer.

To discuss how each diode parameter impacts on the FF, we analyzed the FF by using an empirical equation with the experimental data obtained. The FF in the ideal solar cells with a negligibly small series resistor ($R_s \approx 0$) and an ideal parallel resistor ($R_p \rightarrow \infty$) is represented by^[29–31]

$$FF_0 = \frac{v_{OC} - \ln(v_{OC} + 0.72)}{v_{OC} + 1}$$
(3)

where v_{OC} is the dimensionless voltage $v_{OC} = qV_{OC}/n_{id}k_BT$. On the other hand, the FF in the practical photovoltaics devices is dependent on both R_s and R_p resistances and thus typically expressed by^[29–31]

$$FF = FF_{s} \left(1 - \frac{v_{OC} + 0.7}{v_{OC}} \frac{FF_{s}}{r_{p}} \right)$$
(4)

where FFs is given by

$$FF_{s} = FF_{0}(1 - 1.1r_{s}) + \frac{r_{s}^{2}}{5.4}$$
(5)

Here, r_s and r_p are the normalized resistances, which are given by $r_s = J_{SC}R_s/V_{OC}$ and $r_p = J_{SC}R_p/V_{OC}$, respectively. We calculated the FF in all the perovskite devices by using Equation (4) with the experimental data evaluated. As summarized in **Table 3**, the FF calculated is in good agreement with the FF measured within an error of less than about 6%. We note that this evaluation is still valid for the devices with a different V_{OC} (see the Supporting Information). This finding indicates that this equation is valid for the estimation of FF even with hysteresis and hence can predict the upper limit of FF in lead-halide perovskite solar cells.

Figure 3 shows the FF calculated by Equation (4) with different R_s and R_p resistances. Here, the photovoltaic parameters were employed for the best device measured under the forward scan: $J_{SC} = 23.8 \text{ mA cm}^{-2}$, $V_{OC} = 1.06 \text{ V}$, and $n_{id} = 1.6$. Note that the other contour maps of FF calculated for the reverse scan and for the perovksite devices with $N_t < 10^{13} \text{ cm}^{-3}$ are illustrated in Figure S5. As shown in Figure 3, the FF is dependent only on the R_s where the R_p is larger than $10^5 \Omega \text{ cm}^2$. Under such large R_p , the FF remains constant even with increasing R_p but still increases from 0.64 to 0.84 with decreasing R_s resistance from 10 to 0.1 $\Omega \text{ cm}^2$. This indicates that the FF in perovskite devices studied is primarily dependent on the R_s resistance rather than the R_p resistance because the R_p resistance is enough large >10⁵ $\Omega \text{ cm}^2$ regardless of the HTL thickness. We therefore conclude that the increased FF in perovksite solar cells is mainly due to the decreased R_s resistance with decreasing HTL thickness. As shown in the figure, the FF could be increased up to ≈0.83 if the R_s resistance were reduced to ≈0.5 $\Omega \text{ cm}^2$ that is reported for crystalline silicon solar cells,^[32–35] and thus PCE could be improved to ≈21%. As reported previously, the conductivity of spiro-OMeTAD can be improved up to ≈10⁻³ S cm⁻¹ by using a

dicationic salt of spiro-OMeTAD (spiro-(TFSI)₂).^[36] If such a highly conductive HTL material is empolyed, the R_s resistance could be reduced to $\approx 3.4 \Omega$ cm² as shown in Figure S6 and hence FF could be improved to 0.77. To achieve $R_s < 1 \Omega$ cm² comparable to that of crystalline silicon solar cells, the contact resistances at the interfaces should be reduced to $<1 \Omega$ cm².

Finally, we discuss the potential improvement in FF in terms of N_t in CH₃NH₃PbI₃ perovskite solar cells. In this estimation, the J_{SC} was fixed to 24 mA cm⁻² as an upper limit. As reported previously, both V_{OC} and n_{id} are dependent on the N_t in the perovskite layer under the direct and SRH recombinations.^[7] Consequently, the FF is also dependent on the N_t because it is a function of J_{SC} , V_{OC} , n_{id} , R_s , and R_p as shown in Equation (4). As shown in **Figure 4**, n_{id} decreases to unity with decreasing N_t , suggesting that the direct recombination is dominant at $N_t < 10^{13}$ cm⁻³. For the resistances observed ($R_s = 6.0 \ \Omega \ cm^2$ and $R_p = 1.0 \times 10^5 \ \Omega \ cm^2$), the FF increases from 0.68 to 0.79 with decreasing N_t from 10^{16} to 10^{13} cm⁻³, and hence the PCE could be improved to $\approx 24\%$. If it is assumed that $R_s = 0.5 \ \Omega \ cm^2$, which is reported for crystalline silicon solar cells,^[32–35] the FF could be increased from 0.79 to 0.89 with decreasing N_t from 10^{16} to $10^{13} \ cm^{-3}$, and hence the PCE could be improved to $\approx 27\%$ as summarized in **Table 4**. We therefore conclude that the FF in perovskite solar cells is strongly dependent on both N_t and R_s resistance, and thus could be improved up to ≈ 0.90 if the perovskite solar cells can be prepared with an extremely low N_t of $<10^{13} \ cm^{-3}$ together with a low R_s of $<1 \ \Omega \ cm^2$.

3. Conclusions

We studied the FF of CH₃NH₃PbI₃ perovskite solar cells with different HTL thicknesses. Both the J_{SC} and V_{OC} were almost independent of the HTL thickness whereas the FF was monotonically improved with decreasing HTL thickness. The R_s and R_p resistances were evaluated from the J-V characteristics in the dark on the basis of the equivalent circuit model. The n_{id} was evaluated from the intensity dependence of V_{OC} . As a result, we found that the improvement in FF is mainly due to the reduced series resistance with decreasing HTL thickness. More importantly, we found that the FF can be reproduced by using an empirical equation for FF with the diode and photovoltaic parameters experimentally obtained. On the basis of this equation, the FF could be improved up to ≈ 0.83 if the R_s resistance was reduced to $\approx 0.5 \ \Omega \ cm^2$ that reported for crystalline silicon devices, resulting in a high PCE of $\approx 21\%$. To achieve such a low R_s , it is required to employ highly conductive HTL materials (e.g. $\approx 10^{-3}$ S cm⁻¹) and also to reduce the contact resistances at the interfaces to $<1 \Omega$ cm². The FF could be increased up to 0.79 if the N_t were reduced to $<10^{13}$ cm⁻³ and hence PCE could be improved to \approx 24%. Furthermore, the FF could be increased to \approx 0.9 if the Nt were reduced to $<10^{13}$ cm⁻³ and the R_s was reduced to those of crystalline silicon solar cells. We therefore emphasize that CH₃NH₃PbI₃ perovskite solar cells have the potential to exhibit the theoretical limit of photovoltaic performance if they could be prepared with both an extremely low N_t of $<10^{13}$ cm^{-3} and a low R_s of $<1 \Omega cm^2$. As such, our quantitative analysis gives a guideline for further enhancement of FF in perovskite solar cells and thus high PCE.

4. Experimental Section

Materials and Sample Preparation: A methanol solution of methylamine (90 mL, 40%, 0.882 M; Wako Pure Chemical Industries, Ltd.) was added drop wise over 10 min to an aqueous solution of HI (96.9 mL, 57 wt%, 1.29 M; Wako Pure Chemical Industries Ltd., Japan) in a 500 mL round bottom flask at 0 °C, and then stirred for 2 h. The precipitates were recovered by evaporation at 50 °C for 30 min. The resultant yellowish raw products were dissolved in ethanol, recrystallized from diethyl ether, and then finally filtered. These steps were repeated three times. After filtration, the white solid products CH_3NH_3I were dried at 60 °C in a vacuum oven for 24 h. Stock solutions ($CH_3NH_3PbI_3$) of 55 wt% (1160 mg mL⁻¹) were prepared by mixing CH_3NH_3I with purified PbI₂ (L0279 for perovskite precursor, Tokyo Chemical Industry Co., Ltd.) at a molar ratio of 1 to 1 in anhydrous *N*,*N*-dimethylformamide (DMF, 99.8%, Sigma–Aldrich) and then stirred at 70 °C overnight in a nitrogen-filled glove box (H₂O and O₂ < 1 ppm).

Fabrication of CH₃NH₃PbI₃ Perovskite Solar Cells: A dense layer of TiO₂ (\approx 40 nm) was coated atop a UV–ozone cleaned F-doped tin-oxide (FTO)-coated glass substrate (a sheet resistance of 12 Ω per square, 25 mm × 25 mm, Asahi Glass Co., Ltd., Japan) by spray-pyrolysis at 470 °C using a bis(isopropoxide)bis(acetylacetonato)titanium(IV) solution (75 wt% in 2-propanol, Sigma–Aldrich) diluted in ethanol (1 : 39, volume ratio). To deposit perovskite films, these dense-TiO₂ substrates were transferred into an inert glove box under a nitrogen atmosphere (H₂O and O₂ < 1 ppm). The CH₃NH₃PbI₃ solution (0.13 mL) was first dropped onto the center of the FTO substrate coated with the dense-TiO₂ layer. The substrate was firstly spun at 5000 rpm for 30 s, and after 6 s anhydrous chlorobenzene (CB, 99.8%, Sigma–Aldrich, 0.3 mL) was quickly dropped onto the center of substrate. The instant color change of films from yellow to brown was observed upon dropping CB solvent. The resulting dark brown films were dried at 100 °C for 10 min. The hole-transporting layer (HTL) was deposited on the perovskite layer

by spin-coating at different velocities, such as 1000, 2000, 4000, and 8000 rpm for 30 s from a solution of 2,2',7,7'-tetrakis(*N*,*N*-di-*p*-methoxyphenylamine)-9,9-spirobifluorene (spiro-OMeTAD, Merck, 72.3 mg) in anhydrous chlorobenzene (CB, 99.8%, Sigma–Aldrich, 1.0 mL) containing 28.8 μ L of 4-*tert*-butylpyridine (Aldrich) and 17.5 μ L of lithium bis(trifluoromethanesulfonyl)imide (Li-TFSI) solution (520 mg Li-TFSI in 1 mL acetonitrile, Sigma–Aldrich). Finally, 80 nm of gold was thermally evaporated on top of the active layer under high vacuum (2.5 × 10⁻⁴ Pa). The final layered structure of these perovskite solar cells is FTO/dense-TiO₂/CH₃NH₃PbI₃/HTL/Au. At least 6 devices were fabricated to ensure the reproducibility of the *J*–*V* characteristics

Measurements: J-V characteristics were measured with a direct-current (DC) voltage and current source/monitor (Keithley, 2611B) in the dark and under the AM1.5G simulated solar illumination with 100 mW cm⁻². The light intensity was corrected with a calibrated silicon photodiode reference cell (Bunkoh-Keiki, BS-520). The intensity-dependent J-V characteristics were measured by using the neutral density (ND) filters. The EQE spectra were measured with a spectral response measurement system (Bunko-Keiki Co., ECT-250D). The power of the incident monochromatic light was kept under 0.05 mW cm⁻², which was measured by a calibrated silicon reference cell. All devices were measured in a nitrogen atmosphere with a metal mask to give an active area of 0.09 cm². Note that averaged parameters are obtained from 12 devices with an HTL thickness of 170 nm and from 6 devices for the others to ensure the reproducibility of the J-V characteristics. The film thickness were measured with an atomic force microscope (Shimadzu, SPM-9600) with a silicon probe (Olympus, a force constant of ≈ 0.15 N m⁻¹) in contact mode.

Supporting Information

Supporting Information is available from the Wiley Online Library or from the author.

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Figures and Figure Captions

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Figure 1. a) J-V characteristics of CH₃NH₃PbI₃ perovskite solar cells with different HTL thickness measured from 1.1 to -0.10 V (reverse scan) with a delay time of 1 s: blue line (310 nm), orange line (230 nm), red line (170 nm), and green line (130 nm) and b) EQE spectra (open circles) and J_{SC} (broken lines) calculated from the EQE and solar spectra of the best device studied.



Figure 2. a) V_{OC} plotted against the logarithm of J_{SC} in the devices with an HTL thickness of 170 nm: forward scan (open squares) and reverse scan (close squares) and b) R_s plotted against the HTL thickness. The solid lines in the panel (a) are drawn by using Equation (2): the slope is 1.6 for the forward scan and 1.3 for the reverse scan. The broken line in the panel (b) represents a linear fit to the experimental data.



Figure 3. Contour map of FF calculated by Equation (4) with different R_s and R_p resistances. In this calculation, the photovoltaic parameters were employed for the best device measured under the forward scan: $J_{SC} = 23.8 \text{ mA cm}^{-2}$, $V_{OC} = 1.06 \text{ V}$, and $n_{id} = 1.6$. The close, gray closed, and open circles indicate the FF for the best device experimentally measured under the forward scan, that calculated with $R_s = 3.4 \Omega \text{ cm}^2$ and $R_p = 1.0 \times 10^5 \Omega \text{ cm}^2$, and that calculated with R_s = 0.5 $\Omega \text{ cm}^2$ and $R_p = 1.0 \times 10^5 \Omega \text{ cm}^2$.



Figure 4. a) n_{id} , b) FF, and c) PCE plotted against the logarithm of N_t for CH₃NH₃PbI₃ perovskite solar cells with different resistances: CH₃NH₃PbI₃ perovskite solar cells with $R_s = 6.0 \Omega \text{ cm}^2$ and $R_p = 1.0 \times 10^5 \Omega \text{ cm}^2$ (close triangles and diamonds) and CH₃NH₃PbI₃ perovskite solar cells with $R_s = 0.5 \Omega \text{ cm}^2$ and $R_p = 1.0 \times 10^5 \Omega \text{ cm}^2$ (open triangles and diamonds). "X" marks represent the photovoltaic parameters for the best device measured under the forward scan.

Table 1. Photovoltaic parameters of $CH_3NH_3PbI_3$ perovskite solar cells with different HTL thickness measured from 1.1 to -0.10 V (reverse scan) with a delay time of 1 s. All the devices were measured in a nitrogen atmosphere with a metal mask to give an active area of 0.09 cm².

HTL thickness [nm] ^{a)}	J _{SC} [mA cm ⁻²]	V _{oc} [V]	FF	PCE [%]				
130	23.6 (23.5 ± 0.08)	1.06 (1.06 ± 0.00)	0.768 (0.759 ± 0.01)	19.2 (18.9 ± 0.22)				
170	23.8 (23.7 ± 0.10)	$1.07 (1.07 \pm 0.01)$	$0.770(0.760 \pm 0.01)$	19.6 (19.2 ± 0.27)				
230	23.5 (23.5 ± 0.05)	1.08 (1.07 ± 0.01)	0.753 (0.746 ± 0.01)	19.1 (18.8 ± 0.18)				
310	23.4 (23.5 ± 0.21)	$1.07 (1.07 \pm 0.01)$	0.720 (0.716 ± 0.00)	18.0 (17.9 ± 0.25)				
^{a)} The values represent the best photovoltaic parameters in the CH ₃ NH ₃ PbI ₃ perovskite solar								

cells with different HTL thicknesses. The photovoltaic parameters in parentheses are averaged for at least 6 devices.

Table 2. Diode parameters of CH₃NH₃PbI₃ perovskite solar cells with different HTL thicknesses.

HTL thickness [nm]	Scan direction	n _{id} a)	$R_{ m s} [\Omega \ m cm^2]^{ m b)}$	$R_{ m p} [\Omega \ { m cm}^2]^{ m b)}$
120	Forward	1.6	6.0	2.0 × 10⁵
130	Reverse	1.3	6.0	2.0 × 10 ⁵
170	Forward	1.6	6.0	1.0 × 10⁵
170	Reverse	1.3	6.0	1.2 × 10⁵
000	Forward	1.6	7.5	8.0 × 10⁵
230	Reverse	1.3	7.5	3.0 × 10⁵
040	Forward	1.6	9.0	2.0 × 10⁵
310	Reverse	1.3	9.0	1.2 × 10⁵

^{a)} The n_{ids} are evaluated from a slope in V_{OC} plotted against the logarithm of J_{SC} based on Equation (2). ^{b)} Both R_s and R_p resistances are obtained from the slope of the J-V charateristics in the dark.

Table 3. FF measured and calculated for CH₃NH₃PbI₃ perovskite solar cells with different HTL thicknesses as a function of the scan directions.

HTL thickness [nm]	Scan direction	FF _{exp}	FF _{cal}	Error [%]
120	Forward	0.710	0.72	1.4
130	Reverse	0.768	0.74	3.8
170	Forward	0.720	0.72	0
170	Reverse	0.770	0.74	4.1
220	Forward	0.688	0.69	0.29
230	Reverse	0.753	0.71	6.0
210	Forward	0.666	0.67	0.60
310	Reverse	0.720	0.68	5.9

Table 4. Present and predicted photovoltaic parameters with various N_t and the diode parameters.

Device parameters		Crystalline silicon				
	Present ^{a)}	Low R _s	Low N _t	Low $N_{\rm t}$ and $R_{\rm s}$	devices ^[32–35, 37–40]	
<i>N</i> t [cm⁻³]	≈10 ¹⁵	≈10 ¹⁵	<10 ¹³	<10 ¹³	<10 ¹³	
n _{id}	1.6	1.6	1	1	1	
$R_{\rm s} \left[\Omega \ \rm cm^2 \right]$	6.0	0.5	6.0	0.5	0.5	
R_0 [Ω cm ²]	1.0 × 10⁵	1.0 × 10⁵	1.0 × 10⁵	1.0 × 10⁵	≈10 ⁴	
$J_{\rm SC}$ [mA cm ⁻²]	23.8	24	24	24	41.8	
Voc [V]	1.06	1.06	1.27	1.27	0.740	
FF	0.720	0.83	0.79	0.89	0.827	
PCE [%]	18.2	21	24	27	25.6	

^{a)} The values represent the best device measured under the forward scan.

The limiting factors in fill factor (FF) of perovskite solar cells are discussed by using an empirical equation based on different thickness of a hole-transporting layer. The FF is primarily dependent on the series resistance and trap density in perovskite devices. The potential strategies for the improvements in FF and PCE are further discussed based on the experimental data.

Keyword: organic-inorganic perovskites, fill factors, series resistances, parallel resistances, ideality factors

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Potential Improvement in Fill Factor of Lead-Halide Perovskite Solar Cells

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Supporting Information

Potential Improvement in Fill Factor of Lead-Halide Perovskite Solar Cells

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1. Hysteresis in CH₃NH₃PbI₃ Perovskite Solar Cells



Figure S1. a) J-V characteristics of CH₃NH₃PbI₃ perovskite solar cells with different HTL thicknesses measured from -0.10 to 1.1 V (forward scan) and from 1.1 to -0.10 V (reverse scan) with a delay time of 1 s: a) 130 nm, b) 170 nm, c) 230 nm, and d) 310 nm. All the devices were measured in a nitrogen atmosphere with a metal mask to give an active area of 0.09 cm².

2. Evaluation of the Ideality Factor (n_{id})



Figure S2. V_{OC} plotted against the logarithm of J_{SC} in CH₃NH₃PbI₃ perovskite solar cells with different HTL thicknesses: a) 130 nm, b) 230 nm, and c) 310 nm. The solid lines are drawn by using Equation (2): the slope is 1.6 for the forward scan and 1.3 for the reverse scan for all the panels.

3. *J*–*V* Characteristics in the Dark



Figure S3. Logarithm of the dark current density plotted against the applied voltage in $CH_3NH_3PbI_3$ perovskite solar cells with different HTL thicknesses: a) 130 nm, b) 170 nm, c) 230 nm, and d) 310 nm. The gray solid lines are extracted by a fit to the experimental data with Equation (1) on the basis of n_{id} evaluated separately.

4. Thickness Dependence of *R*_s in Au/spiro-OMeTAD/Au Configuration.



Figure S4. Series resistance plotted against the thickness of spiro-OMeTAD films in the configuration of Au/spiro-OMeTAD/Au. The solid line represents a linear fit to the experimental data.

5. Contour Map of FF



Figure S5. Contour map of FF calculated by Equation (4) with different R_s and R_p resistances. In this calculation, a) the photovoltaic parameters were employed for the best device measured under the reverse scan: $J_{SC} = 23.8 \text{ mA cm}^{-2}$, $V_{OC} = 1.07 \text{ V}$, and $n_{id} = 1.3$. b) the photovoltaic parameters were employed for the perovskite device with N_t of $<10^{13} \text{ cm}^{-3}$: $J_{SC} = 24 \text{ mA cm}^{-2}$, $V_{OC} = 1.27 \text{ V}$, and $n_{id} = 1.0$. The close, gray closed, and open circles indicate the FF for the best device experimentally measured under reverse scan, that calculated with $R_s = 3.4 \Omega \text{ cm}^2$ and $R_p = 1.0 \times 10^5 \Omega \text{ cm}^2$, and that calculated with $R_s = 0.5 \Omega \text{ cm}^2$ and $R_p = 1.0 \times 10^5 \Omega \text{ cm}^2$.

6. Series Resistance Plotted against the Logarithm of HTL Conductivity



Figure S6. Series resistance plotted against the logarithm of HTL conductivity. The broken line represents the remaining constant component $(3.4 \Omega \text{ cm}^2)$ in the Figure 2b.

7. FF Measured and Calculated for Perovskite Solar Cells

Table S1.	FF cal	culated for	CH ₃ NH ₃ PbI ₃	perovskite	solar	cells	with a	different	$V_{\rm OC}$.
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<i>N</i> t [cm ⁻³] ^{a)}	n _{id} a)	J _{SC} [mA cm ⁻²] ^{a)}	<i>V</i> _{OC} [V] ^{a)}	FF ^{a)}	Method ^{b)}	$R_{\rm s}$ [Ω cm ²]	$R_{ m p}$ [Ω cm ²]	FF_{cal}	Error [%]
≈5.0 × 10 ¹⁶ 2.7	27	0.7 17.0	1.00	0.60	Dark	6.0	5.0 × 10 ²	0.62	3.3
	17.0	1.00		Illumination	10.1	2.4 × 10 ⁴	0.62	3.3	
≈1.0 × 10 ¹⁶ 2.0	2.0	20 221	1.04	0.73	Dark	6.0	1.0 × 10⁵	0.70	4.3
	22.1	1.04		Illumination	4.7	7.3 × 10 ³	0.72	1.4	
~2 0 ~ 1015	15	22.0	1.09	0.75	Dark	6.0	1.0 × 10⁵	0.73	2.7
~3.0 ^ 10 * 1.3	1.5	1.5 23.9	1.00		Illumination	4.9	3.9 × 10 ³	0.74	1.4

^{a)} N_t , n_{id} , and photovoltaic parameters are taken from the previous literature.^[S1] ^{b)} R_s and R_p resistances are evaluated from the *J*–*V* charateristics in the dark and under illumination.

Reference

[S1] H. D. Kim, H. Ohkita, H. Benten, S. Ito, Adv. Mater. 2016, 28, 917.